

L Number	Hits	Search Text	DB	Time stamp
1	486	VDMOS or Vertical near double near diffused near Metal near oxide near semiconductor	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/06/10 08:05
8	17	implant with (epi near layer) and (punch near through)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/06/10 08:08
15	1	(VDMOS or Vertical near double near diffused near Metal near oxide near semiconductor) and (implant with (epi near layer) and (punch near through))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/06/10 08:10
22	4	"5729037"	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2002/06/10 08:18
29	1		USPAT	2002/06/10 08:11
30	1		USPAT	2002/06/10 08:15
31	1		USPAT	2002/06/10 08:16
32	1		USPAT	2002/06/10 08:16
33	1		USPAT	2002/06/10 08:17
34	1		USPAT	2002/06/10 08:17
35	1		USPAT	2002/06/10 08:17
36	1		USPAT	2002/06/10 08:18

5,731,611
 5,529,940
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6,391,723-
 6,278,155-
 6,165,821
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 6,094,104
 5,907,776-^(*)